

10/81/90

ISSUE CLASSIFICATION	
Class	Subclass

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.

PATENT DATE

SCANNED

Q.A.

APPLICANTS

WILEY

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1741

Method and apparatus for low temperature annealing of metallization micro-structure in the production of a microelectronic device

PTO-2040
12/89

ISSUING CLASSIFICATION

ORIGINAL						CROSS REFERENCE(S)						
CLASS			SUBCLASS			CLASS		SUBCLASS (ONE SUBCLASS PER BLOCK)				
INTERNATIONAL CLASSIFICATION												

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	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
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